



**RESPONSE UNDER 37 CFR 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1762**

PATENT
Attorney Docket No. 400113/ASAHI NA *11/18/02*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

HIROAKI SATOH

Application No. 09/271,447

Art Unit: 1762

Filed: March 18, 1999

Examiner: M. Cleveland

For: PROCESS FOR FORMING A PATTERN
OF FLUORESCENT SUBSTRATE AND
PLASMA DISPLAY PANEL

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RESPONSE TO OFFICE ACTION

Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

In response to the Office Action dated August 13, 2002, please enter the following amendments and consider the following remarks along with the accompanying Declaration under 37 C.F.R. § 1.132. Pages showing the requested changes are attached. This response is accompanied by a RCE.

AMENDMENTS

IN THE CLAIMS:

Replace the indicated claims with:

X

1. (Three Times Amended) A process for forming a pattern of fluorescent substance into the cell of a fluorescent substance display substrate comprising providing inside the cell two separate layers which are (i) a resin composition (A) layer and (ii) a photosensitive resin composition (B) layer, exposing the layers to light, developing the exposed layers, and baking the developed layers; wherein the resin composition (A) layer consists essentially of an acrylic polymer (a) having a weight average molecular weight of 10000 to 300000 and an acid number